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PATENT TRADEMARK OFFICE

Patent *answ*
Case No.: 57181US002

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

First Named Inventor: BAUDE, PAUL F.

Application No.: 10/076003 Group Art Unit: 2814

Filed: February 14, 2002 Examiner: H. Trinh

Title: APERTURE MASKS FOR CIRCUIT FABRICATION

AMENDMENT AND RESPONSECommissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450CERTIFICATE OF TRANSMISSIONTo Fax No.: 703-872-9318
I hereby certify that this correspondence is being facsimile transmitted to the U.S. Patent
and Trademark Office on:June 27, 2003
DateHylia H. Froelke
Signed by: Hylia H. Froelke

Dear Sir:

This is in response to the Office Action mailed on March 28, 2003. Reconsideration of the application is requested in view of the following remarks.

In the Claims

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Please amend claim 20 to read as follows:

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20. (amended) An integrated circuit comprising:
a deposition substrate;
a patterned first electrode layer formed adjacent the deposition substrate;
a patterned organic semiconductor layer formed adjacent the first electrode layer;
and
a second patterned electrode layer deposited adjacent the organic semiconductor
layer, wherein the patterned first electrode layer, the patterned organic semiconductor
layer, and the second patterned electrode layer are each defined by a repositionable
aperture mask.

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Please add new claims 39 and 40:

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**Office of Intellectual Property Counsel
3M Innovative Properties Company****3M Center, PO Box 33427
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Date: June 27, 2003

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To: Patent and Trademark Office
Examiner H. Trinh
Art Unit 2814

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Remarks: Urgent Acknowledge Reply ASAP Please Comment

AMENDMENT AND RESPONSE

Title: "APERTURE MASKS FOR CIRCUIT FABRICATION"

Application Number: 10/076003

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First Named Inventor: Baude, Paul F.

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Attorney Case Number: 57181US002